## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ln re P	atent of	f			)
Dromard, Adrien et al.					)
Patent No.: 7,799,304					
lssued: September 21, 2010					
Title:	Highly-Structured Silica Having a Low Water Uptake, Preparation Method Thereof and Uses of Same				
		F	REQUEST FO	R CER	TIFICATE OF CORRECTION
P.O. B	issionei ox 1450 idria, V <i>i</i>	)			
Issuance of a Certificate of Correction for the above-captioned patent is respectfully requested in accordance with the accompanying Form PTO-1050.					
		The re	quisite govern	ment f	ee of \$100.00:
			is authorized	to be o	charged to Deposit Account No. 02-4800; or
			charge to cre	dit car	d. Form PTO-2038 is attached.
		It is believed that payment of a fee is unnecessary. Attached is Form PTO-1050 indicating a printer error on the Title Page (Section 30) Foreign Application Priority Data			
The Director is hereby authorized to charge any appropriate fees under 37 C.F.R. § 1.20(a) that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800.					
	mer No.		,	By:	Respectfully submitted, BUCHANAN INGERSOLL & ROONEY PC  Norman H. Stepno Registration No. 22,716
703 836 6620					

## UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.

7,799,304

APPLICATION NO. :

10/583,417

ISSUE DATE

September 21, 2010

INVENTOR(S)

Dromard, Adrien

It is certified that an error appears or errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Title Page, Section (30) Foreign Application Priority Data: change "Dec. 19, 2003" to --Dec. 19, 2004---.

MAILING ADDRESS OF SENDER:

PATENT NO. 7,799,304

Buchanan Ingersoll & Rooney PC P.O. Box 1404 Alexandria, VA 22313-1404

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